



## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the application of:

Masao TOMIKAWA et al.

Serial No. 10/790,800

Filing Date: March 3, 2004

For: POSITIVE PHOTOSENSITIVE RESIN

PRECURSOR COMPOSITION AND PROCESS FOR PRODUCING THE

**SAME** 

Examiner: John S. Y. Chu

Group Art Unit: 1752

## **AMENDMENT UNDER 37 CFR 1.111**

MS Amendment Commissioner for Patents

P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Action dated March 7, 2005, please amend this application as follows:

The specification amendments begin on page 2.

The listing of claims begins on page 3.

The Remarks begin on page 8.